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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/617,770	07/14/2003	Takashi Hamada	740756-2628	4042	
22204	7590 11/29/2006		EXAMINER		
	NIXON PEABODY, LLP			LIN, JAMES	
401 91H ST SUITE 900	401 9TH STREET, NW SUITE 900		ART UNIT	PAPER NUMBER	
WASHING	ΓON, DC 20004-2128	1762			
			DATE MAILED: 11/29/2006		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)
	10/617,770	HAMADA, TAKASHI
Office Action Summary	Examiner	Art Unit
	Jimmy Lin	1762
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	correspondence address
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period w  - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tinuity will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).
Status		
Responsive to communication(s) filed on <u>03 Octoor</u> This action is <b>FINAL</b> . 2b) ☐ This      Since this application is in condition for allowar closed in accordance with the practice under Expression in the practice of the pract	action is non-final.	
Disposition of Claims		
4) ⊠ Claim(s) 1-16 is/are pending in the application.  4a) Of the above claim(s) is/are withdray  5) □ Claim(s) is/are allowed.  6) ⊠ Claim(s) 1-16 is/are rejected.  7) □ Claim(s) is/are objected to.  8) □ Claim(s) are subject to restriction and/or	wn from consideration.	
Application Papers		
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) accomplicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Examine	epted or b) objected to by the drawing(s) be held in abeyance. Se tion is required if the drawing(s) is ob	e 37 CFR 1.85(a). ejected to. See 37 CFR 1.121(d).
Priority under 35 U.S.C. § 119		
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:  1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority document application from the International Bureau * See the attached detailed Office action for a list	s have been received. s have been received in Applicat rity documents have been receiv u (PCT Rule 17.2(a)).	ion No ed in this National Stage
Attachment(s)  1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08)	4) Interview Summar Paper No(s)/Mail D 5) Notice of Informal	Pate
Paper No(s)/Mail Date <u>10/3/06</u> .	6)	

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#### **DETAILED ACTION**

## Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:
  - 1. Determining the scope and contents of the prior art.
  - 2. Ascertaining the differences between the prior art and the claims at issue.
  - 3. Resolving the level of ordinary skill in the pertinent art.
  - 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.
- 3. Claims 1-12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Hamada et al. (6,114,183) in view of Shoji et al. (JP-10158638).

Hamada discloses method of manufacturing an EL device, comprising:

depositing a TFT 33 over a substrate (Fig. 8);

forming an electrode 13 which is electrically connected with the TFT (column 6, lines 62-64);

forming a light emitter 14 containing an organic compound over the first electrode (column 3, lines 42-43);

forming a second electrode 16 over the light emitter (column 3, lines 46-47).

Hamada does not explicitly teach that the second electrode is formed using an electron beam evaporation method, wherein an acceleration voltage of electrons is controlled such that radial rays are not substantially radiated from an evaporation material for forming the second electrode when the evaporation material is irradiated with an electron beam. However, the selection of something based on its known suitability for its intended use has been held to support a prima facie case of obviousness. Sinclair & Carroll Co. v. Interchemical Corp., 325

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U.S. 327, 65 USPQ 297 (1945). Shoji teaches a method of producing an EL device, wherein the second electrode is formed over the organic EL layer using an electron beam vapor deposition method. The acceleration voltage of an electron is controlled such that, when an accelerated electron is irradiated on a vapor-depositing material, a radial ray is not substantially radiated from the vapor-depositing material [0013]. The acceleration voltage is controlled to prevent the reduction of fluorescence in the organic EL layer [0024]. Although Shoji does not explicitly teach that acceleration voltage is controlled such that the thin film transistor (TFT) is not deteriorated with radial rays, the lack of radial rays in the process will prevent any deterioration of the TFT. Therefore, it would have been obvious to one of ordinary skill in the art at the time of invention to have formed the second electrode of Hamada via an electron beam vapor deposition method with a reasonable expectation of success because Shoji teaches that electron beam vapor deposition is a suitable method for depositing the second electrode and that the operating conditions in this method does not radiate radial rays that can deteriorate the fluorescent properties of the EL layers.

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Because a radial ray is not substantially radiated from the vapor-depositing material by controlling the acceleration voltage of electrons, the TFT is not deteriorated with radial rays and the sub-threshold coefficient does not increase.

Claims 5,6: Shoji teaches that the second electrode can have a thickness in the range of approximately 10 nm to 1  $\mu$ m [0019].

Shoji does not explicitly teach that control is performed such that a time during which the TFT is exposed to radial rays is shortened to avoid deterioration of the TFT when the evaporation material is irradiated with an electron beam. However, Shoji teaches that the acceleration voltage directly affects the film-forming speed [0026], which inversely affects deposition time. In other words, as the acceleration voltage increases, the deposition rate increases while the deposition time decreases. Because the acceleration voltage is controlled, the film-forming speed and deposition time is indirectly controlled. A particular parameter can be recognized as a result-effective variable, i.e., a variable which achieves a recognized result, and the determination of the optimum or workable ranges of said variable might be characterized as routine experimentation. In re Antonie, 559 F.2d 618, 195 USPQ 6 (CCPA 1977). Therefore, it would have been obvious to one of ordinary skill in the art at the time of invention to have

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increased the acceleration voltage through routine experimentation in order to find the optimal balance between the deposition rate and the release of radial rays. The TFT exposure to radial rays would necessarily be shortened due to the shortening of the time required for deposition.

Claims 7-12: Shoji teaches that the vapor-depositing material comprises of a metal component and an alkali earth metal [0017].

Claims 13-16: A radial ray is not substantially radiated from the vapor-depositing material [0013].

## Response to Arguments

4. Applicant's arguments filed 10/3/2006 have been fully considered but they are not persuasive.

Claims 1-12 as rejected over Hamada '183 and Shoji '638:

The Applicant argues that Shoji's disclosure does not recognize the problem of the thin film transistor having a shift of a sub-threshold voltage after having been radiated with radial rays. The Applicant further argues that without recognizing the problem, there can be no suggestion or motivation for improving the characteristic abnormality of the thin film transistors in Shoji and Hamada. However, radial rays from the electron beam evaporation method of an evaporation material appears to cause the shift in the sub-threshold voltage. Because Shoji teaches that a radial ray is not substantially radiated from the evaporation material, radial rays are not present to cause such a shift. Although Shoji does not recognize the problem of the TFT having a shift, such is a shift is necessarily prevented due to the lack of radial rays, wherein the lack of radial rays is controlled by controlling the acceleration voltage of electrons.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jimmy Lin whose telephone number is 571-272-8902. The examiner can normally be reached on Monday thru Friday 8AM - 5:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tim Meeks can be reached on 571-272-1423. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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#### Conclusion

5. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after

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the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

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> KEITH HENDRICKS PRIMARY EXAMINER